



IPW

Docket No.: R2180.0193/P193

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Naohiro Ueda

Application No.: 10/801,838

Confirmation No.: 3147

Filed: March 17, 2004

Art Unit: 2814

For: SEMICONDUCTOR APPARATUS AND
METHOD OF MANUFACTURING THE
SAME

Examiner: W. M. Fahmy

RESPONSE TO RESTRICTION REQUIREMENT

U.S. Patent and Trademark Office
220 20th Street S.
Customer Window, Mail Stop Amendment
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed February 21, 2006 (Paper No. 20060207), Applicant hereby provisionally elects claims 1-10 for continued examination.

The Examiner has required restriction between claims 11-16 drawn to a method of making a semiconductor apparatus; and claims 1-10 drawn to a semiconductor apparatus.

Applicant hereby elects Group II (claims 1-10) and cancels claims 11-16, without prejudice, to expedite allowance of this matter.

Applicant reserves the right to file one or more divisional applications directed towards the subject matter of the non-elected claims.

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If the Examiner believes an interview would be of assistance, the Examiner is welcome to contact the undersigned at the number listed below.

Dated: March 10, 2006

Respectfully submitted,

By

Ian R. Blum

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